# WEST Search History

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DATE: Tuesday, February 06, 2007

| Hide? | Set Name | Query | Hit Count |
|---|---|---|---|
| | | *DB=PGPB,USPT,USOC; PLUR=YES; OP=ADJ* | |
| ☐ | L40 | (hydrofluoric or (hydrogen fluoride) or HF) adj10 purity adj10 (water adj (content or concentration or ppm)) | 3 |
| ☐ | L39 | (hydrofluoric or (hydrogen fluoride) or HF) adj10 grade adj10 (water adj (content or concentration or ppm)) | 0 |
| ☐ | L38 | (hydrofluoric or (hydrogen fluoride) or HF) adj5 grade adj5 (water adj (content or concentration or ppm)) | 0 |
| ☐ | L37 | (hydrofluoric or (hydrogen fluoride) or HF) adj5 purity adj5 (water adj (content or concentration or ppm)) | 2 |
| ☐ | L36 | (hydrofluoric or (hydrogen fluoride) or HF) adj5 purity adj5 water | 30 |
| ☐ | L35 | L33 with (semiconductor or wafer) | 19 |
| ☐ | L34 | L33 with (etching or cleaning) | 25 |
| ☐ | L33 | (hydrofluoric or (hydrogen fluoride) or HF) adj5 purity | 379 |
| ☐ | L32 | (hydrofluoric or hydrogen fluoride or HF) adj5 purity | 379 |
| ☐ | L31 | l29 and l26 | 16 |
| ☐ | L30 | l29 same (residue or $5resist or contaminant or polymer) | 11 |
| ☐ | L29 | (((carbon dioxide) or "CO.sub.2") with (dens$5 or $5critical)) same (HF or (hydrogen fluoride) or hydrofluoric) same (water or "H.sub.2O") | 118 |
| ☐ | L28 | (residue or $5resist or contaminant) same (((carbon dioxide) or "CO.sub.2") with (dens$5 or critical)) same (HF or (hydrogen fluoride) or hydrofluoric) same (water or "H.sub.2O") | 2 |
| ☐ | L27 | L26 and l18 | 15 |
| ☐ | L26 | 134/2,3,31,36,42;438/906.ccls. | 8214 |
| ☐ | L25 | l18 with (dens$5 or critical or supercritical) | 62 |
| ☐ | L24 | l18 same (dens$5 or critical or supercritical) | 163 |
| ☐ | L23 | l20 adj10 (dens$5 or critical or supercritical) | 5 |
| | | *DB=EPAB,JPAB,DWPI; PLUR=YES; OP=ADJ* | |
| ☐ | L22 | l21 adj10 (dens$5 or critical or supercritical) | 0 |
| ☐ | L21 | ((carbon dioxide) or "CO.sub.2") adj5 ((water or "H.sub.2O") adj3 (concentration or content)) | 85 |
| | | *DB=PGPB,USPT,USOC; PLUR=YES; OP=ADJ* | |
| ☐ | L20 | ((carbon dioxide) or "CO.sub.2") adj5 ((water or "H.sub.2O") adj3 (concentration or content)) | 748 |
| ☐ | L19 | ((carbon dioxide) or "CO.sub.2") adj7 ((water or "H.sub.2O") adj5 | 1063 |

| | | | |
|---|---|---|---|
| | | (concentration or content)) | |
| ☐ | L18 | ((carbon dioxide) or "CO.sub.2") with ((water or "H.sub.2O") adj5 (concentration or content)) | 2423 |
| ☐ | L17 | ((carbon dioxide) or "CO.sub.2"l8) with ((water or "H.sub.2O") adj5 (concentration or content)) | 1790 |
| ☐ | L16 | l8 same (supercritical or critical or dens$5) | 27 |

*DB=EPAB,JPAB,DWPI; PLUR=YES; OP=ADJ*

| | | | |
|---|---|---|---|
| ☐ | L15 | l8 same (supercritical or critical or dens$5) | 41 |

*DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI; PLUR=YES; OP=ADJ*

| | | | |
|---|---|---|---|
| ☐ | L14 | l8 same (supercritical or critical or dens$5) | 68 |

*DB=USPT; PLUR=YES; OP=ADJ*

| | | | |
|---|---|---|---|
| ☐ | L13 | l11 and (semiconductor or substrate or workpiece or article) | 18 |

*DB=EPAB,JPAB,DWPI; PLUR=YES; OP=ADJ*

| | | | |
|---|---|---|---|
| ☐ | L12 | l10 and (semiconductor or substrate or workpiece or article) | 1 |

*DB=USPT; PLUR=YES; OP=ADJ*

| | | | |
|---|---|---|---|
| ☐ | L11 | (residue or $5resist or contaminant) same ((carbon dioxide) or "CO.sub.2") same (HF or (hydrogen fluoride)) same (water or "H.sub.2O") same (clean$3 or treat$3 or remov$3) | 28 |

*DB=EPAB,JPAB,DWPI; PLUR=YES; OP=ADJ*

| | | | |
|---|---|---|---|
| ☐ | L10 | (residue or $5resist or contaminant) same ((carbon dioxide) or "CO.sub.2") same (HF or (hydrogen fluoride)) same (water or "H.sub.2O") same (clean$3 or treat$3 or remov$3) | 50 |

*DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI; PLUR=YES; OP=ADJ*

| | | | |
|---|---|---|---|
| ☐ | L9 | (residue or $5resist or contaminant) same ((carbon dioxide) or "CO.sub.2") same (HF or (hydrogen fluoride)) same (water or "H.sub.2O") same (clean$3 or treat$3 or remov$3) | 203 |
| ☐ | L8 | (residue or $5resist or contaminant) same ((carbon dioxide) or "CO.sub.2") same (HF or (hydrogen fluoride)) same (water or "H.sub.2O") | 231 |
| ☐ | L7 | L6 and ((residue or $5resist or contaminant) same ((carbon dioxide) or "CO.sub.2") same (HF or (hydrogen fluoride)) same (water or "H.sub.2O")) | 1 |
| ☐ | L6 | L5 or l4 or l3 or l2 | 55847 |
| ☐ | L5 | (kobe steel).as. | 54677 |
| ☐ | L4 | (kabushiki kaisha kobe seiko sho).as. | 1441 |
| ☐ | L3 | iijima-katsuyuki$.in. | 44 |
| ☐ | L2 | masuda-kaoru$.in. | 102 |

*DB=USPT; PLUR=YES; OP=ADJ*

| | | | |
|---|---|---|---|
| ☐ | L1 | 6277753.pn. or 5868862.pn. or 6203406.pn. | 3 |

END OF SEARCH HISTORY